

## Reactions at Functional Silicon Centres in Compounds Containing Carbon–Zinc Bonds

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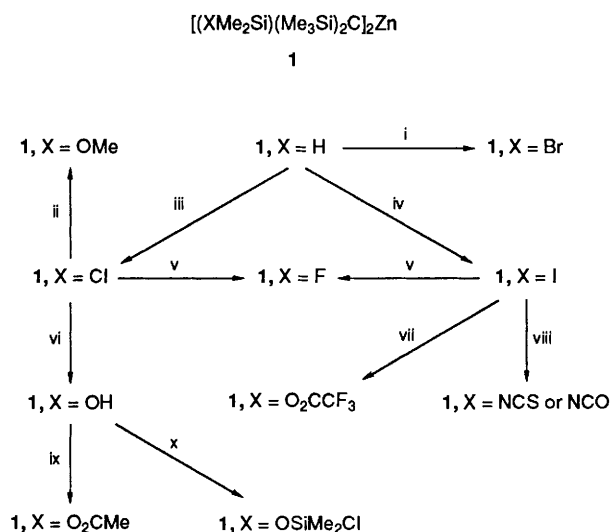
Substitutions at the Si–X bonds in the compounds  $[(XMe_2Si)(Me_3Si)_2C]_2Zn$ , some involving powerful electrophiles, take place without cleavage of the C–Zn bonds.

Some years ago we reported the remarkable chemical and thermal stability of the substituted-dimethylzinc  $[(Me_3Si)_3C]_2Zn$ , illustrating its robustness by, among other ways, purifying it by steam distillation.<sup>1</sup> We have now found that the C–Zn bonds in the related species **1** are, for steric reasons, so resistant to attack that substitutions, often involving powerful electrophiles, can be carried out at the Si–X bonds without breakdown of the molecule. The reactions have been used to prepare a range of remarkable organozinc compounds containing functional groups that could not normally coexist with Zn–C bonds.

The entry into the series of compounds was provided by the reaction with  $ZnBr_2$  of the organolithium reagent  $(HMe_2Si)(Me_3Si)_2CLi$ , itself made by reaction of  $(HMe_2Si)(Me_3Si)_2-$

$CCl$  with BuLi in  $Et_2O$ –tetrahydrofuran at  $-110^\circ C$ . The hydride **1**,  $X = H$ , thus obtained was treated with ICl,  $Br_2$  or  $I_2$ , respectively, to give the halides **1**,  $X = Cl, Br$  or  $I$ , and from these the compounds **1** with  $X = F, OH, OMe, O_2CCF_3, O_2CMe, NCS, NCO$  and  $OSiMe_2Cl$  were obtained, directly or indirectly, by standard organosilicon reactions, as shown in Scheme 1. It is noteworthy that the C–Zn bonds are unaffected by such vigorous electrophiles as halogens,  $CF_3CO_2H, MeCOCl, Me_2SiCl_2$  and the hydrogen halides generated in many of the reactions shown in Scheme 1.

The identities of the compounds, all crystalline solids, were established in the usual ways, including elemental analysis, NMR spectroscopy [some typical  $\delta_H$  values for solutions in  $CCl_4$ , are (for  $Me_3Si, Me_2Si,$  and  $X$ , respectively);  $(X =) H,$



**Scheme 1** Reagents: i, Br<sub>2</sub>-CCl<sub>4</sub>; ii, MeOH; iii, ICl (2.5 molar proportion in CCl<sub>4</sub>); iv, I<sub>2</sub>-CCl<sub>4</sub>; v, AgBF<sub>4</sub>-CH<sub>2</sub>Cl<sub>2</sub>; vi, H<sub>2</sub>O-tetrahydrofuran; vii, Ag<sub>2</sub>O/CF<sub>3</sub>CO<sub>2</sub>H; viii, AgSCN or AgOCN in CH<sub>2</sub>Cl<sub>2</sub>; ix, MeCOCl; x, Me<sub>2</sub>SiCl<sub>2</sub>

0.21, 0.28 (d), 4.36 (septet); OH, 0.21, 0.30, 2.67 (br); OMe, 0.18, 0.24, 3.34; F, 0.34, 0.42 (d); I, 0.37, 1.06] and mass spectrometry (in all cases strong peaks were observed for the [M - Me]<sup>+</sup> ions, and in most cases weaker peaks for the [M]<sup>+</sup> ions), and for 1, X = Cl, OH, OMe and O<sub>2</sub>CCF<sub>3</sub>, by X-ray crystallography.

A feature of interest is that the preparation of 1, X = OSiMe<sub>2</sub>Cl, opens up the possibility of obtaining linear and cyclic polysiloxanes incorporating stable Si-C-Zn-C-Si linkages in their backbones.

Many of the related compounds [(XMe<sub>2</sub>Si)(Me<sub>3</sub>Si)<sub>2</sub>C]<sub>2</sub>M with M = Hg or Cd have been made analogously.

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## References

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